Application No. Applicant(s) 10/066,849 LEE ET AL. Notice of Allowability Art Unit Examiner John Ruggles 1756 -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address--All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308. 1. This communication is responsive to the amendment filed 5/11/05. 2. The allowed claim(s) is/are 1,2 and 4-14. 3. The drawings filed on <u>04 February 2002</u> are accepted by the Examiner. 4. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) 🔯 All b) Some* c) None 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. _____ 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)). * Certified copies not received: ___ Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient. 6. CORRECTED DRAWINGS (as "replacement sheets") must be submitted. (a) including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d). DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL. Attachment(s) 1. Notice of References Cited (PTO-892) 5. Notice of Informal Patent Application (PTO-152) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 6. Interview Summary (PTO-413), Paper No./Mail Date 3. Information Disclosure Statements (PTO-1449 or PTO/SB/08), 7. X Examiner's Amendment/Comment Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit

8. X Examiner's Statement of Reasons for Allowance

Other .

Notice of Allowability

John Ruggles

Examiner, Art Unit 1756

571-272-1390

of Biological Material

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EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Michael Hull on 7/8/05.

The application has been amended as follows:

IN THE SPECIFICATION:

At page 1 line 12, change "limit results" to --limited results--.

At page 1 line 18, change "self-align" to --self-aligned--.

At page 4 line 17, change "of semiconductor device" to --of a semiconductor device--.

At page 5 line 22, change "using dual damascene process" to --using <u>a</u> dual damascene process--.

At page 7 line 26, change "a the void" to --a the void--.

At page 9 line 7, change "via hole 39 (see Figs. 3C-3E)" to --via hole 39 (see Figs. 3E-3E)--.

At page 9 line 13, change "may be maximized the etch profile" to --may be maximized so that the etched profile--

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IN THE CLAIMS:

At claim 1 line 17, delete the phrase "at least" before "partially covering the via hole".

At claim 7 lines 3-4, change "either by plasma" to --by either by plasma--.

Allowable Subject Matter

Claims 1-2 and 4-14 are allowed.

The following is an examiner's statement of reasons for allowance: the prior art does not clearly teach all the specific limitations of the instant claims as currently amended and especially does not show forming a fourth interlayer insulating layer on the portion of a second etching stop layer disposed around the inlet of a via hole and an exposed portion of a third interlayer insulating layer and partially covering the via hole (claim 1), wherein a void is formed in the fourth interlayer insulating layer (claim 6). For at least this reason, claims 1 and 6 are allowable over the prior art. Claims 2 and 4-14 depend on claim 1 are therefore allowable over the prior art.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to John Ruggles whose telephone number is 571-272-1390. The examiner can normally be reached on Monday-Thursday and alternate Fridays.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on 571-272-1385. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

John Ruggles

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MARK F. HUFF
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 1700